

U.S. Department of Commerce, Patent and Trademark Office	Atty Docket No.	Serial No.
	M-12347 US	N/A
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicants
(Use several sheets if necessary)		Paul E. Brunemeier, Archita Sengupta, Justin F. Gaynor, Robert H. Haveman
		Filing Date
		Herewith

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U.S. Patent Documents

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
AA		6,329,062 B1	12/11/02	Gaynor	428	447	
AB		6,260,949 B1	7/17/01	Smith, et al.	347	44	
AC							
AD							
AE							
AF							
AG							
AH							
AI							

Foreign Patent Documents

							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
	AJ	9-230600	9/5/97	Japan	H01L	21.30	X	
	AK	2000-199963	7/18/00	Japan	H01L	21.30	X	
	AL	2000-199962	7/18/00	Japan	H01L	21.30	X	

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

AM	Kikkawa, Takamaro, "Proceedings of the International Electronic Devices Meeting," 12/10-13/00, pp. 253-256.
AN	Levy, David, "Electrooptical Devices from Organically Doped sol-Gel Materials," Mol. Crust. And Liq. Cryst. 1000, Vol. 354, pp. 159-165.
AO	Katz, Alexander and Davis, Mark E., "Molecular imprinting of bulk, microporous silica, Nature Vol 403 20 January 2000.
AP	Jalone, Paavo and Tuominen, Aulis, "The Applicability of Electrodeposited Photoresist in Producing Ultra-fine Lines Using Sputtered Seeding Layers," IEEE 2000 In'l. Symp on Electronic Materials &

Examiner _____ Date Considered _____

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through entire row if reference is not being considered. If reference is being considered, draw line through entire row.